New Crystalline Silica Ruling Is Topic at June 21
CONN-OSHA Employer Roundtable Meeting

WETHERSFIELD, June 9, 2016 – Recently-issued OSHA guidelines on the acceptable exposure limit of Crystalline silica is the topic at the June 21 Breakfast Roundtable Discussion Group sponsored by the Connecticut Department of Labor’s Division of Occupational Safety and Health (CONN-OSHA). The popular informational employer roundtable will be held 8:15 to 9:45 a.m. at the Labor Department’s Central Office, 200 Folly Brook Boulevard in Wethersfield.

Guest speaker is Ana Ellington of Business & Legal Resources (BLR) who specializes in writing federal and state regulatory summaries and develops compliance and educational materials for safety programs. She will address the health issues associated with Crystalline silica and how they relate to an organization and the key provisions of the final rule and compliance requirement issues.

“The new guideline, issued this past March, sets limits of exposure to Crystalline silica, a common substance found in soil that can potentially cause lung cancer, silicosis, chronic obstructive pulmonary and kidney disease,” explains John Able, CONN-OSHA Occupational Safety Training Specialist and roundtable project coordinator.

He noted that Ellington will focus on practical impacts the recently-issued ruling will have on the new exposure limit for silica exposure control measures, medical surveillance, training workers about silica-related hazards, and recordkeeping measures.

There is no admission to the roundtable but pre-registration is required. Please contact Able at john.able@ct.gov to register for the event or for additional information.

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